

Claims

- [c1] 1. A process for removing SO_2 , NO , and NO_2 from a gas stream comprising the steps of
- oxidizing at least a portion of NO in a gas stream to NO_2 with an oxidizing means, followed by
 - scrubbing at least a portion of SO_2 , NO , and NO_2 from the gas stream with a scrubbing solution comprising ammonia, and having a pH between 6 and 8, and
 - removing at least a portion of any ammonia aerosols generated from the scrubbing step from the gas stream with an aerosol removal means.
- [c2] 2. The process of claim 1, wherein said oxidizing means is an electrical discharge reactor.
- [c3] 3. The process of claim 2, wherein said electrical discharge reactor is a dielectric barrier discharge reactor.
- [c4] 4. The process of claim 3, further comprising the step of oxidizing at least a portion of the NO to HNO_3 with said dielectric barrier discharge reactor.
- [c5] 5. The process of claim 1, wherein said oxidizing step is adapted to result in a mole ratio of SO_2 to NO_2 of at least 2.5 to 1.
- [c6] 6. The process of claim 1, wherein said oxidizing step is adapted to result in a mole ratio of SO_2 to NO_2 of at least four to one.
- [c7] 7. The process of claim 1, said scrubbing solution comprising ammonia, ammonium sulfite, ammonium sulfate, and water, and having a pH between 6 and 8.
- [c8] 8. The process of claim 1, wherein said aerosol removal means is a wet electrostatic precipitator.
- [c9] 9. The process of claim 1, wherein said scrubbing step results in the formation

of ammonium sulfate, the process further comprising the step of withdrawing ammonium sulfate from the scrubbing solution.

- [c10] 10. The process of claim 4, wherein said scrubbing step results in the formation of ammonium nitrate, the process further comprising the step of withdrawing ammonium nitrate from the scrubbing solution.
- [c11] 11. A process for removing SO_2 , NO , NO_2 , and Hg from a gas stream comprising the steps of
- oxidizing at least a portion of the NO in a gas stream to NO_2 , and at least a portion of the Hg in a gas stream to HgO , with an oxidizing means, followed by
 - scrubbing at least a portion of the SO_2 , NO , and NO_2 from the gas stream with a scrubbing solution comprising ammonia, and having a pH between 6 and 8, and
 - removing at least a portion of any ammonia aerosols generated from the scrubbing step, and HgO , from the gas stream with an aerosol removal means.
- [c12] 12. The process of claim 11, wherein said oxidizing means is an electrical discharge reactor.
- [c13] 13. The process of claim 12, wherein said electrical discharge reactor is a dielectric barrier discharge reactor.
- [c14] 14. The process of claim 11, wherein said aerosol removal means is a wet electrostatic precipitator.
- [c15] 15. The process of claim 11, said scrubbing solution comprising ammonia, ammonium sulfite, ammonium sulfate, and water, and having a pH between 6 and 8.
- [c16] 16. The process of claim 15, wherein said scrubbing step results in the formation of ammonium sulfate, the process further comprising the step of withdrawing ammonium sulfate from the scrubbing solution.

- [c17] 17. An apparatus for removing SO_2 , NO , and NO_2 from a gas stream comprising
- a. an oxidizing means for oxidizing at least a portion of the NO in a gas stream to NO_2 , followed by
 - b. a scrubber suitably adapted to scrub at least a portion of the SO_2 , NO , and NO_2 from the gas stream with a scrubbing solution comprising ammonia, and having a pH between 6 and 8, and
 - c. an aerosol removal means for removing at least a portion of any ammonia aerosols generated by the scrubber from the gas stream.
- [c18] 18. The apparatus of claim 17, wherein said oxidizing means is at least one electrical discharge reactor.
- [c19] 19. The apparatus of claim 18, wherein said electrical discharge reactor is at least one dielectric barrier discharge reactor.
- [c20] 20. The apparatus of claim 19, wherein said dielectric barrier discharge reactor is adapted to oxidize at least a portion of the NO to NO_2 and HNO_3 .
- [c21] 21. The apparatus of claim 17, said scrubbing solution comprising ammonia, ammonium sulfite, ammonium sulfate, and water, and having a pH between 6 and 8.
- [c22] 22. The apparatus of claim 17, wherein said aerosol removal means is at least one wet electrostatic precipitator.
- [c23] 23. An apparatus for removing SO_2 , NO , NO_2 , and Hg from a gas stream comprising
- a. an oxidizing means for oxidizing at least a portion of the NO in a gas stream to NO_2 , and at least a portion of the Hg in a gas stream to HgO , followed by
 - b. a scrubber suitably adapted to scrub at least a portion of the SO_2 , NO , and NO_2 from the gas stream with a scrubbing solution comprising ammonia, and having a pH between 6 and 8, and

c. an aerosol removal means for removing at least a portion of any ammonia aerosols generated by the scrubber, and HgO, from the gas stream.

- [c24] 24. An apparatus for removing SO_2 , NO, and NO_2 from a gas stream comprising
- an NO oxidizer adapted to oxidize at least a portion of the NO in a gas stream to NO_2 , followed by
 - a scrubber adapted to scrub at least a portion of the SO_2 , NO, and NO_2 from the gas stream with a scrubbing solution comprising ammonia, and having a pH between 6 and 8, and
 - an aerosol remover adapted to remove at least a portion of any ammonia aerosols generated by the scrubber from the gas stream.
- [c25] 25. The apparatus of claim 24, wherein said NO oxidizer is at least one electrical discharge reactor.
- [c26] 26. The apparatus of claim 25, wherein said electrical discharge reactor is at least one dielectric barrier discharge reactor.
- [c27] 27. The apparatus of claim 26, wherein said dielectric barrier discharge reactor is adapted to oxidize at least a portion of the NO to NO_2 and HNO_3 .
- [c28] 28. The apparatus of claim 24, said scrubbing solution comprising ammonia, ammonium sulfite, ammonium sulfate, and water, and having a pH between 6 and 8.
- [c29] 29. The apparatus of claim 24, wherein said aerosol remover is at least one wet electrostatic precipitator.